

RESPONSE UNDER 37 C.F.R. § 1.116 -- EXPEDITED PROCEDURE -EXAMINING GROUP 2800

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Applica	tion of:)			
Han-Ming Wu et al.) Examin	Examiner: Nguyen, Hung		g
Serial No:	09/752,938) Art Un	it:	2851	
Filed:	December 29, 2000)			
For:	Purging Gas from a Photolithography Enclosure Between a Mask Protective Device and a Pattern Mask))))		(GD	TECH
RESPONSE TO OFFICE ACTION					
Mail Stop AF Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450 Sir: In Response to the Final Office Action mailed on April 25, 2003, the Applicants respectfully request that the Examiner enter the following amendments and consider the following remarks.					
FIRST CLASS CERTIFICATE OF MAILING					
Service as first cla	at I am causing the above-referenced corns mail with sufficient postage on the da ommissioner for Patents, P.O. Box 1450	e indicated below an	d that this	h the United State paper or fee has be	s Postal een
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Nieta Mathis M July 23, 2003 Signature Date					
		Date			